Petabit-Scale Silicon Photonic Interconnects with Integrated Kerr Frequency Combs

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Abstract-Silicon photonics holds significant promise in revolutionizing optical interconnects in data centers and high performance computers to enable scaling into the Pb/s package escape bandwidth regime while consuming orders of magnitude less energy per bit than current solutions. In this work, we review recent progress in silicon photonic interconnects leveraging chipscale Kerr frequency comb sources and provide a comprehensive overview of massively scalable silicon photonic systems capable of capitalizing on the large number of wavelengths provided by such combs. We first consider the high-level architectural constraints and then proceed to detail the corresponding fundamental device designs supported by both simulated and experimental results. Furthermore, the majority of experimentally measured devices were fabricated in a commercial 300 mm foundry, showing a clear path to volume manufacturing. Finally, we present various system-level experiments which illustrate successful proof-ofprinciple operation, including flip-chip integration with a codesigned CMOS application-specific integrated circuit (ASIC) to realize a complete Kerr comb-driven electronic-photonic engine. These results provide a viable and appealing path towards future co-packaged silicon photonic interconnects with aggregate perfiber bandwidth above 1 Tb/s, energy consumption below 1 pJ/bit, and areal bandwidth density greater than 5 Tb/s/mm².

Index Terms—Silicon photonics, optical frequency combs, wavelength division multiplexing.

I. INTRODUCTION

THE past decade has seen unprecedented growth of the digital world, spearheaded by the rapid rise to ubiquity of data-intensive workloads such as artificial intelligence and deep learning. Simultaneously, as Moore's Law draws to a

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Optical frequency combs, consisting of equidistant tones in the frequency domain with intrinsically precise spacing, have been widely studied in a variety of systems beginning with mode-locked lasers [4], [5] and were the subject of the 2005 Nobel Prize in Physics [6]. The miniaturization of these frequency combs to the chip scale has sparked a second revolution in the field, promising to provide unprecedented performance in a mass-producible form factor which can be realized using the same complementary metaloxide-semiconductor (CMOS) infrastructure currently used to fabricate commercial microelectronics chips [7]-[10]. Over the span of the past decade, these integrated Kerr frequency combs have found widespread use across a broad application space including optical metrology [11], optical frequency synthesis [12], quantum optics [13], spectroscopy [14], [15], long-haul telecommunications [16]–[21], and most recently short-reach data communications [22]–[26]. In the context of both longand short-reach data communications, integrated optical frequency combs have drawn significant interest as wavelengthdivision multiplexing (WDM) sources, providing the alluring prospect of a single multi-wavelength source with tens to hundreds of equally-spaced carrier frequencies at standard ITU channel spacing. Furthermore, these sources have the potential to reside on a single chip [27], [28] which can either be directly integrated with the transmitter chip [29] or reside outside of the transceiver package as a remote light source [30].



Fig. 1. Bandwidth density-energy efficiency product as a function of distance (adapted from Gordon Keeler, DARPA ERI Summit 2019). A full system leveraging the work detailed in this paper would represent a six order-of-magnitude improvement in figure of merit compared to currently available pluggable optical transceivers.

Traditional optical interconnect approaches using pluggable transceivers require high-speed signals to propagate through centimeters of lossy metallic waveguides before conversion to the optical domain and typically provide a maximum of only four channels at high baud rates. These high-speed signals require complex serialization/deserialization (SerDes), digital signal processing (DSP), and clocking circuits to interface with the compute ASIC (CPU, GPU, etc.) which consumes large amounts of energy and adds significant latency. The combination of these requirements and the long electrical signal paths between pluggable transceivers and compute ASICs presents a severe bottleneck to further scaling the link bandwidth and energy efficiency. However, through leveraging the tens to hundreds of wavelengths provided by Kerr frequency combs, each WDM channel can be run at modest data rates to drastically reduce the gearboxing requirements at the compute ASIC interface while maintaining ultra-high aggregate bandwidth due to the massive wavelength parallelism. Thus, through realizing Kerr comb-driven co-packaged silicon photonic interconnects with millimeter-scale electrical signal paths between the electronics and photonics, fundamentally new computing architectures can be explored in data centers and high performance computing systems.

By removing the strong constraint of data locality imposed by lossy, distance-dependent electrical interconnects through providing ultra-high bandwidth, distance-agnostic WDM links with ultra-low energy consumption and latency, disaggregated architectures become feasible in which resources can be pooled and optically connected over long distances without relying on each server to be configured with a standard von Neumann architecture [31], [32]. Furthermore, with all data emerging from the compute package already in the optical domain, novel optical circuit switching topologies can be employed to partition and route the multi-wavelength data streams such that bandwidth is allocated to best match the system-level traffic patterns without costly O-E-O conversions [33], [34]. Therefore, the proposed Kerr comb-driven silicon photonic interconnects have the potential not only to alleviate the current data center bandwidth bottleneck, but to enable a fundamentally new class of distributed computing systems.

Here, we outline a comprehensive co-designed electronicphotonic interconnect leveraging the massive parallelism of integrated Kerr frequency combs capable of realizing 1 Tb/s/fiber data transmission while consuming as low as 100 fJ/b with an areal bandwidth density greater than 5 Tb/s/mm². While the strategies employed to reach these metrics represent a substantial departure from current state-of-the-art silicon photonic solutions, all of the described avenues are fundamentally compatible with high-volume manufacturing and thus represent a realistic path for continued scaling of optical interconnects into the Pb/s regime.

II. LINK ARCHITECTURE

The burden of (de-)multiplexing hundreds of comb lines into independent buses, where each bus supports only a single channel with a single modulator/receiver, is prohibitive in terms of footprint and energy consumption requirements. By taking advantage of the wavelength selectivity of resonant modulators and filters, the number of buses can be substantially reduced and thus relax these requirements. However, restrictions stemming from the resonator free spectral range (FSR) and off-resonance insertion loss typically limit the use of traditional single bus architectures in cases where the comb bandwidth exceeds the FSR. In these cases, we propose two distinct regimes of comb pre-division into sub-groups prior to traversing cascaded resonators: band interleaving and even-odd interleaving. This section details the benefits and drawbacks of all three permissible link architecture regimes (single bus, band interleaving, and even-odd interleaving), taking a holistic view including footprint, energy consumption, loss, and ease of implementation. The link-level trade-offs and considerations discussed in this section motivate the application-specific device designs and innovations in the subsequent sections.

A. Single Bus

Through cascading microresonators of varying radii on a single bus waveguide, individual resonators can address independent target wavelength channels while appearing transparent to other channels on the bus (Fig. 2a) [35]–[38]. While non-target channels will suffer from the off-resonance insertion loss associated with other resonators, this loss can be made exceptionally low with careful device design ($\sim 0.1 \text{ dB}$). For this architecture, the predominant roadblock to scaling in channel count is not insertion loss but rather the FSR restriction associated with the spectral periodicity of resonant cavities. Since the spectrum of each resonator exhibits dips at each integer multiple of the FSR, these unwanted resonances prevent packing of more channels since they would result in high crosstalk due to overlap with non-target channels. While the FSR restricts the number of channels for a particular channel spacing, more channels can be added for a fixed FSR if the channel spacing is reduced. However, it has been shown that spacings below ~ 100 GHz result in severe intermodulation crosstalk [39] and thus places a lower bound on how much the channel spacing can be reduced. Given these restrictions, for a state-of-the-art resonant modulator array at 100 GHz channel spacing with 25.6 nm FSR [40], this architecture can support a maximum of 32 WDM channels. While smaller resonators with a larger FSR are being explored



Fig. 2. **a**, Schematic of the single bus architecture, where the resonant wavelength of each device is tuned to match its corresponding comb line. **b**, Schematic of the band interleaving architecture in which the comb is first sub-divided into groups before traversing cascaded resonators, halving the total comb bandwidth at each stage while preserving channel spacing. **c**, Schematic of the even-odd interleaving architecture which pre-divides the comb into even and odd groups, doubling the channel spacing at each stage while nearly preserving total comb bandwidth.

as a means of further increasing the channel capacity of the single bus architecture [41]–[43], such devices have drawbacks including increased design/implant complexity and lack of space for integrated heaters due to their inherently small footprint. Despite high efficiency carrier depletion resonant modulators being capable of compensating ~ 10 K temperature swings without thermal tuning [43], [44], it is unlikely that this mechanism will be sufficient in real co-packaged thermal environments ($\Delta T > 80$ K) and thus necessitates the use of integrated heaters. Furthermore, despite the low off-resonance insertion loss, for high device counts cascaded on a single bus this can accumulate to an appreciable power penalty (i.e., [64 - 1 channels] × 0.1 dB = 6.3 dB). These restrictions on the scalability of the single bus architecture motivate the use of multi-bus architectures to support ultra-high channel counts.

B. Band Interleaving

Band interleaving is the natural extension of the single bus architecture in which the comb is first split into 'bands' of adjacent lines before traversing separate buses of cascaded resonators (Fig. 2b). As described for the single bus architecture, if the comb bandwidth is greater than the resonant modulator/filter FSR, pre-filtering is necessary to accommodate channels beyond the capacity of a single bus. Through sub-dividing the comb in this manner, the original comb channel spacing is preserved and the total bandwidth on each bus (and number of channels per bus) is reduced by a factor of 2^{S-1} , where S is the number of interleaver stages. This architecture is particularly appealing since the number of interleaver stages can be chosen such that the comb bandwidth on each bus is smaller than the resonator FSR, thus mitigating any undesirable interactions between target and alias resonances. However, the main drawback lies at the device level rather than the system level; that is, the toolbox of compact, tunable silicon photonic devices which can perform band interleaving in this manner is scarce and demonstrated devices lack the necessary performance in terms of pass-band roll-off, crosstalk suppression, and tunability. Mach Zehnderbased wavelength filters have a pass-band roll-off proportional to their FSR, and thus the large FSR required for band interleaving (at least half of the total comb bandwidth) leads to unfeasible roll-off. Even for modified MZI designs targeted at flattening the pass-bands and sharpening the roll-off (such as ring-assisted MZIs [45], [46] and cascaded MZI lattices [47]), the demonstrated roll-off for large FSRs is still insufficient and would lead to severe crosstalk near the band transition. Onchip dichroic filters have been demonstrated as a candidate for similar filtering applications [48], but similarly have poor rolloff (2.82 dB/nm), insufficient crosstalk suppression (< 10 dB), and lack tunability to correct for fabrication imperfections and temperature swings.

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However, contra-directional couplers have shown significant promise as band interleaving devices and typically occupy much smaller footprints than MZI-based filters. Demonstrations have shown 4 channel flat-top CWDM demultiplexers with $\sim 1 \text{ mm}^2$ footprint [49], [50], device tunability through carrier injection in p-i-n junctions [51], and large stopband filters with bandwidths > 33 nm [52]. While such wavelength filters based on contra-directional couplers hold potential for band interleaving solutions, their implementation in such systems is currently restricted by their gradual passband roll-off which would result in lost comb lines near the band edges in demonstrated devices. Furthermore, fabricating sharp subwavelength structures in foundry processes using DUV lithography necessitates sophisticated optical proximity correction (OPC) to achieve the desired device geometry and requires the use of computational lithography to accurately simulate the device (accounting for lithography effects such as corner rounding) [53]. If these lithography effects are accurately calibrated for a given foundry process and device advancements lead to sharper passband roll-off, contra-directional couplerbased wavelength filters will provide a viable and appealing path to enabling massively wavelength-parallel silicon photonic links using band interleaving architectures.

C. Even-Odd Interleaving

Even-odd interleaving is an alternate path to sub-dividing the comb into separate buses in which the comb is split into 'even' and 'odd' groups, with each stage doubling the channel spacing of the output groups and preserving the total comb bandwidth on each bus (Fig. 2c). In this architecture, the pass-band roll-off is a more nuanced issue than in the band interleaving case. For band interleaving, it was shown that poor roll-off directly results in unusable comb lines and/or reduced performance of comb lines that reside near the pass-band edge.



Fig. 3. Multi-FSR channel design with $N_{ch} = \mathcal{F} = 7$ and $\mathcal{S} = 3$. **a**, Enumerated resonances for a resonator with target comb line 0 (other resonator resonances are omitted for clarity). Each channel appears $\mathcal{S} \cdot \lambda_{ag}$ nanometers away from its nearest neighbor, while each alias appears a multiple of $\mathcal{F} \cdot \lambda_{ag}$ away from its parent channel. **b**, Enumerated resonances on the same bus, now including the next resonator with target comb line 6. Since \mathcal{S} and \mathcal{F} are co-prime, the distance the aliases are from their parent channel will never be divisible by \mathcal{S} thus enabling no overlap with another channel. **c**, Fully enumerated example for all resonator resonances on the bus. For a link satisfying the design relations discussed in this section, all resonators will be properly aligned to their corresponding target comb line while all other alias resonances land λ_{ag} away from their nearest non-target comb line.

For even-odd interleaving, this requirement is relaxed since the periodicity of the interleaver spectrum results in maximum transmission/rejection of desired comb lines regardless of rolloff, assuming perfect alignment and that the interleaver free spectral range (FSR) is both constant and exactly twice the channel spacing of the comb. For this reason, the library of suitable devices is much more expansive than that for band interleaving, making this architecture much more favorable for system implementation. Furthermore, each successive stage doubles the channel spacing and halves the number of channels per bus, relaxing constraints on crosstalk and insertion loss. However, since this architecture preserves the total comb bandwidth on each bus, if the comb bandwidth is greater than the resonator FSR then great care must be taken in constructing the channel arrangement such that device 'alias' resonances do not overlap with other 'target' resonances [22], [24].

1) Valid Multi-FSR Channel Arrangement: Since the channel bandwidth on each bus is approximately the same as the total link bandwidth for even-odd interleavers, consideration must be given to preventing 'alias' resonances from inducing severe crosstalk penalties for the other 'target' channels on a given bus. When choosing the design of an even-odd interleaver link, there exist two distinct regimes of operation: (i) single-FSR regime and (ii) multi-FSR regime. In the single-FSR regime, the microresonator FSR is designed to be larger than the total optical bandwidth on the bus. This design guarantees that any alias resonances fall outside of the optical bandwidth, allowing all channels maximal protection from both crosstalk and dispersion walk-off. The multi-FSR regime, in contrast, uses microresonators with FSRs that are smaller than the total optical bandwidth on the bus. Alias resonances will fall in between each channel at regular intervals, effectively reducing the spacing between each channel and its nearest aggressor. The suitability for each regime for a given link depends on the optical bandwidth of the comb source and the physical constraints on the resonator FSR. While a single-FSR design is a simple solution to the alias resonance problem for small optical bandwidths, designing resonators for larger optical bandwidths runs the risk of requiring physical dimensions that may be infeasible due to both fabrication constraints and excess bend radiation losses [44]. Although the relaxed requirement on the resonator FSR for the multi-FSR regime is provided at the cost of additional crosstalk, multi-FSR designs are an attractive alternative that allows for aggressive scalability in total link bandwidth without requiring potentially infeasible resonator designs.

While any FSR larger than the link bandwidth will work in the single-FSR regime, only particular combinations of FSR and channel aggressor values can result in a valid multi-FSR design [24]. To properly analyze this trade-off between increased channel crosstalk and resonator FSR, we must define the requisite conditions which must be satisfied for a valid arrangement. We first define two auxiliary variables for designing the FSR:

$$S = \frac{\lambda_{ch}}{\lambda_{ag}} \tag{1a}$$

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$$\mathcal{F} = \frac{FSR}{\lambda_{ag}} \tag{1b}$$

where λ_{ch} is the channel spacing on each bus, λ_{ag} is the reduced spacing between each channel and its nearest aggressor alias, N_{ch} is the total number of channels on each bus, and FSR is the resonator free spectral range.

The quantities \mathcal{F} and \mathcal{S} represent the resonator FSR and channel spacing normalized to the aggressor spacing. Together, they describe all possible multi-FSR channel arrangements. The normalized nature of both variables allows us to explicitly define the two conditions that $\mathcal F$ and $\mathcal S$ must follow such that they yield a valid channel arrangement: (i) \mathcal{F} and \mathcal{S} must be co-prime integers (i.e. they have no common factors other than 1), and (ii) \mathcal{F} must be greater than or equal to N_{ch} . By ensuring that \mathcal{F} and \mathcal{S} follows these conditions, it is guaranteed that no resonance aliases will land on any target wavelength within the bandwidth of the link (Fig. 3). Choosing $\mathcal{F} = N_{ch}$ corresponds to the fairest channel reduction case in which each channel experiences the same increase in crosstalk. Choosing \mathcal{F} to be greater than N_{ch} means that one or more aggressor aliases won't appear on the bus. The special case where S = 1 corresponds to the minimum FSR required for the single-FSR regime.

2) Multi-FSR Design Space Exploration: Once all constraints are defined, a design space boundary can be drawn such that solutions inside the boundary meet the design constraints. From this, a final optimization that maximizes the key priorities for the link (e.g. aggressor spacing) can be



Fig. 4. Multi-FSR design space with constraints $N_{ch} = 16$, FSR_{max} = 40 nm, FSR_{min} = 16 nm, and $\lambda_{ag} \ge 100$ GHz. Each blue scatter point represents a valid multi-FSR design. Greyed out scatter points indicate designs that fall outside of the stated constraints. **a**, Design constraints for $\lambda_{ch} = 400$ GHz in S- \mathcal{F} space. **b**, Identical design constraints to **a** plotted in FSR- λ_{ag} space. **c**, Design space for $\lambda_{ch} = 600$ GHz in FSR- λ_{ag} space. **d**, Design space for $\lambda_{ch} = 800$ GHz in FSR- λ_{ag} space.

performed. An example of this is provided in Fig 4a. Each co-prime S-F pair that falls within or on the boundary are valid link configurations that can be considered as a design candidate. Additionally, by using equations (1a) and (1b), each S-F pair can be converted into a corresponding FSR- λ_{ag} pair, as shown in Fig. 4(b).

A key goal at this stage is to choose an optimal FSR and aggressor spacing which both meet the design requirements for the link and maximize the minimum aggressor spacing. For the same design constraints, additional solutions can be added by increasing the value for the channel bus spacing through either adding additional interleaver stages or increasing the original comb line spacing (Fig. 4(c-d)). By the definition of (1a), a lower value for S corresponds to a larger aggressor spacing and therefore lower level of crosstalk. The quantity Sis normalized to the channel spacing, which is determined by $\lambda_{ch} = 2^L \cdot \lambda_{comb}$, where L is the number of interleaver stages and λ_{comb} is the spacing of the comb source. In common integrated comb sources (e.g. Kerr combs and quantum dot mode locked lasers, discussed further in Section III), the channel spacing is directly related to the cavity path length which can't be tuned post-fabrication to any appreciable fraction of the FSR. Therefore, choosing a link design which accounts for worst-case fabrication-induced walk-off in the source channel spacing is critical to ensuring yield.

Although the link design formalism outlined in this section omits dispersion for simplicity, typical silicon photonic resonators have non-zero dispersion which must be considered. This dispersion results in a wavelength-dependent FSR and will thus disrupt the placement of alias resonances over broad bandwidths. If the resonator FSR is designed with respect to a 'nominal' wavelength, the severity of this dispersion will increase the farther away an alias is from the nominal wavelength. The impact of this alias placement disruption is consequently a function of the total optical bandwidth on a



Fig. 5. **a**, Schematic of the coupled-microresonator system for normal GVD comb generation [54]. **b**, Microscope image of the fabricated Si_3N_4 device [55]. **c**, Experimentally measured comb spectrum in the low-noise state.

given bus, which cannot be reduced when using even-odd interleavers as noted earlier. Though there is some variation in the dispersion between microdisk designs, the difference is too small for any choice in S-F pair to meaningfully compensate for using a large optical bandwidth. Considering both sources of non-idealities (imperfect comb spacing and dispersion), each S-F pair must be explicitly simulated to ensure that the resulting λ_{ag} provides enough of a margin.

III. INTEGRATED KERR FREQUENCY COMB SOURCE

At the heart of such massively wavelength-multiplexed interconnects is the optical frequency comb source. In this section, we focus our analysis on Kerr frequency combs in the Si_3N_4 platform due to their highly appealing properties, but additionally provide comparisons to other platforms for comb generation. We then present the design and fabrication of dispersion-engineered coupled-resonator Si_3N_4 Kerr combs in the normal group velocity dispersion (GVD) regime, and conclude with experimental characterizations of a representative fabricated device.

A. Comparison of Frequency Comb Sources

Integrated optical frequency comb sources can be categorized under two broad classifications: semiconductor modelocked lasers (SMLLs) and nonlinearly generated combs [56]. As this work is focused on short-reach data communications, we restrict our discussion to comb sources which can be integrated on-chip and fabricated in standard high-volume processes. Electrically-pumped quantum dot SMLLs have been widely demonstrated both as external comb sources [57] and integrated directly on-chip [58], [59] with sufficient performance for communications applications. While such sources can provide tens of high-quality wavelength channels, their total bandwidth is fundamentally restricted by the gain bandwidth of the active region material and thus scaling to the regime of hundreds of channels is infeasible. Additionally, due to restrictions on the cavity optical path length in such devices, typical channel spacings are much less than typical dense wavelength-division multiplexing (DWDM) standards (~ 20 GHz versus 100 GHz) which can lead to significantly increased crosstalk. Furthermore, the native output power-per-line is typically much lower than the link budget and thus necessitates power-hungry pre-amplification prior to the transmitter.

Integrated comb sources based on parametric nonlinear generation have been demonstrated in various material platforms including thin film lithium niobate (using both χ^2 [60] and χ^3 [29] processes), AlGaAs-on-insulator [61], and silicon nitride (Si₃N₄) [8], [27], [28], [55]. Such sources are highly appealing since only a single continuous-wave (CW) pump laser is required to generate hundreds of new frequencies with inherently precise spacing. Electro-optic combs in the thin film lithium niobate platform have been demonstrated with excellent performance in terms of conversion efficiency and number of lines [60], [62], but with the drawbacks of low power-per-line, inherent spectral roll-off, and small channel spacing which depends on the speed of the microwave drive signal. However, combs generated using the χ^3 nonlinearity ('Kerr combs') in Si₃N₄ microresonators represent an ideal platform due to their CMOS compatibility and since they do not require a high-speed microwave drive signal for comb generation. Additionally, since this physical process for comb generation is parametric, such sources are not restricted by an active material gain bandwidth and thus have been shown to be capable of spanning over an octave in the near IR, encompassing all telecommunication bands [63].

However, integrated Kerr frequency combs in Si₃N₄ have traditionally suffered from three major inherent drawbacks which were thought to preclude their use as short-reach DWDM sources: (i) low optical power per line, (ii) low pump-to-comb conversion efficiency, and (iii) non-uniformity in line power. Many of these properties are particular to soliton Kerr combs in the anomalous GVD regime, which have fundamental physical restrictions on conversion efficiency (< 5% [64]) and flatness (due to their inherent sech² envelope). However, nonsolitonic Kerr combs in the normal GVD regime have recently emerged as a promising alternative, as they have been experimentally shown to have pump-to-comb conversion efficiencies as high as 41%, high power-per-line (> 0.5 mW), and tailorable spectral envelopes. Furthermore, we have recently shown that such nonsolitonic Kerr combs can be synchronized and coherently combined [65], [66] to achieve otherwise unattainable power-per-line and equalize the spectrum for improved flatness. Due to the combination of these highly favorable properties, such nonsolitonic Kerr combs provide a unique path to realizing chip-scale multiwavelength sources capable of efficiently producing hundreds of evenly-spaced high power lines.

B. Coupled-Microresonator Design and Fabrication

Comb generation using localized anomalous GVD provided by an avoided mode crossing in coupled microresonator systems has been shown to be a reliable method for creating highly efficient multi-wavelength sources with high coherence [54], [55]. Furthermore, such devices can leverage independent thermal tuning of both resonators to alter the bus-ring and ring-ring coupling conditions post-fabrication to control the spectral position and splitting strength of the avoided crossing, allowing for a fixed-wavelength pump laser. Furthermore, the low-noise comb state can persist over a wide heater power range (in contrast to highly sensitive soliton states), providing stable operation in the presence of environmental temperature perturbations. For our representative device, we design the waveguide cross-section to be $730 \times 1,000$ nm such that the fundamental TE₀ mode experiences normal GVD near the pump wavelength. Furthermore, by designing the main ring FSR to be slightly offset from the auxillary ring FSR (200 GHz and 206 GHz, respectively), we leverage the Vernier effect to control the spectral periodicity of the mode interactions to limit low-power comb lines in the bandwidth of interest.

To fabricate the Si₃N₄ microresonators, we first start from a 4-inch silicon wafer and thermally grow a 4- μ m thick oxide layer to form the bottom cladding. Next, we deposit Si₃N₄ using low-pressure chemical vapor deposition (LPCVD) in two steps and then anneal at 1,200 °C in an argon atmosphere for 3 hours. After the Si_3N_4 deposition, we then deposit a SiO_2 hard mask using plasma-enhanced chemical vapor deposition (PECVD). Electron beam lithography is then used to pattern the Si₃N₄ devices. We write the pattern using Ma-N 2403 resist and etch the nitride film in an inductively coupled plasma reactive ion etcher (ICP RIE) using a combination of CHF₃, N₂, and O₂ gases. After stripping the oxide mask, the devices are again annealed to remove residual N-H bonds in the Si₃N₄ layer. The devices are then clad with 500 nm of high-temperature silicon dioxide (HTO) deposited at 800 °C followed by 2 μ m of SiO₂ using PECVD. A deep etched facet and an inverse taper are designed and used to minimize the edge coupling loss. Further information and extended discussion regarding the device fabrication can be found in [67], [68].

C. Experimental Characterization

Due to the thermally tunable avoided mode crossing, we demonstrate deterministic computer-controlled mode-locked comb generation using a fixed frequency pump laser source $(\lambda = 1559.79)$ [55]. Furthermore, to demonstrate fully general turn-key operation across different operating conditions, we show deterministic low-noise comb generation for multiple combinations of ring-ring coupling gap and pump wavelength. We experimentally characterized the pump-to-comb conversion efficiency of the fabricated normal GVD coupled-resonator Kerr combs to be as high as 41% when the comb is in the low noise mode-locked state and observed high coherence (> 94%) for all comb lines across the full spectrum, suitable for both intensity-modulated and coherent communications. Further details regarding the device characterization can be found in [55].

IV. EVEN-ODD (DE-)INTERLEAVERS

In the proposed link architecture, the (de-)interleaver is the first device traversed by the comb for multi-bus configurations. Due to the difficulties associated with on-chip implementation of band interleaving, we focus our discussion on



Fig. 6. **a**, Schematic of the ultra-broadband interleaver demonstrating its principle of operation. **b**, Optical microscope image of the fabricated device. **c**, Full device transmission spectrum demonstrating uniform performance over 125 nm in the C- and L-bands. **d**, Zoomed section of the spectrum over a 25 nm bandwidth showing flat-top pass- and stop-bands with ~ 15 dB crosstalk suppression [45].

even-odd interleavers. In particular, we examine ring-assisted MZI (RAMZI) interleavers due to their compact footprint, tunability, and flat-top pass-bands compared to the sinusoidal response of standard asymmetric MZIs. Despite the maturity of such devices, there exist a number of hurdles associated with standard designs which must be overcome for their consideration in ultra-low energy consumption silicon photonic links. In this section, we outline the exact challenges associated with their adoption and demonstrate solutions which reduce their energy consumption by orders-of-magnitude compared to standard designs.

A. Ultra-Broadband Performance

The broad bandwidth spanned by the comb requires all devices in the circuit to have predictable and uniform behavior over the full comb bandwidth. Often, this bandwidth can be greater than 100 nm and thus places considerable strain on the devices, which are often highly wavelength-dependent for standard designs. To accommodate combs with > 100 channels at 100 GHz spacing, we demonstrate an ultra-broadband silicon photonic interleaver capable of interleaving and deinterleaving frequency comb lines over a 125 nm bandwidth from 1525-1650 nm, spanning the full C- and L-bands and representing the broadest operational bandwidth to date for an on-chip interleaver [45]. The device consists of a ringassisted Mach Zehnder interferometer (RMZI) with broadband coupling to the ring and broadband mutli-mode interference (MMI) splitter/combiners, enabling consistent performance over the full bandwidth of interest. Previous demonstrations of silicon photonic interleavers have been restricted to usable spectral bandwidths less than 70 nm due to the use of standard directional couplers which are highly wavelength dependent [46], [69]. A schematic overview of the device is shown in Fig. 6a, highlighting the tunable broadband coupler to the ring needed for uniformity in the wavelength-dependent phase shift over the full comb bandwidth. The broadband 50-50 couplers in the balanced MZI are designed using phase-control sections as described in [70]. The device was taped out as part of a multi-project wafer (MPW) run in Advanced Micro Foundry's (AMF) 200 mm silicon photonics process. An optical microscope image of the fabricated device is shown in Fig. 6b. The experimentally measured transmission spectrum of the device is shown in Fig. 6c-d, with flat-top pass- and stop-bands maintained over the full 125 nm bandwidth and a typical crosstalk suppression around 15 dB. This demonstration enables the previously proposed link designs using an even-odd interleaving architecture to operate with comb bandwidths spanning 125 nm and therefore support over 150 wavelength channels at 100 GHz spacing.

B. Ultra-Efficient Thermal Phase Shifters

Thermal phase shifters are widely used to correct for fabrication-induced phase errors and temperature swings in silicon photonic devices due to the large thermo-optic coefficient of silicon $(\frac{dn}{dT} = 1.8 \times 10^{-4} \text{ K}^{-1})$. This is particularly true for ring-assisted MZI interleavers, which are highly phasesensitive in both ring resonance location and path length imbalance, necessitating at least two phase shifters per device. However, such phase shifters typically consume on the order of tens of milliwatts per element and are susceptible to large intra-chip parastic crosstalk. For these reasons, elementary thermal devices do not meet the performance requirements inherent in large-scale, low-energy photonic interconnects. However, the efficiency of thermal devices can be dramatically increased by selectively removing the silicon substrate under the heater, effectively eliminating the path of lowest thermal



Fig. 7. **a**, Cross-sectional view of a standard silicon waveguide with doped silicon heater lines running parallel. **b**, Cross-sectional view of the waveguide and heaters after substrate undercut, effectively air cladding the system for thermal isolation. **c**, Steady-state finite element simulation for the standard geometry, showing a $\Delta T \sim 4$ K change in the waveguide temperature for 5 mW dissipated power. **d**, Identical simulation for the undercut geometry also with 5 mW dissipated power, demonstrating a dramatic increase in waveguide temperature ($\Delta T \sim 315$ K). **e**, Microscope image of the unmodified foundry chip with air trenches down to BOX. **f**, Microscope image of the chip after postprocessing using inductively coupled plasma reactive ion etching (ICP RIE) to expose the substrate and a vapor phase xenon diffouride (XeF₂) etch to selectively remove the substrate. **g**, Measured thermal efficiency of the undercut device, demonstrating $P_{\pi} = 1.2$ mW. **h**, Measured frequency response of the standard and undercut devices.

resistance and thus isolating the device [71], [72]. In this section, we present and experimentally validate a thermally isolated phase shifting cell fabricated in a commercial 300 mm CMOS foundry, which exhibits low-crosstalk and low-power operation [73]. While minimal post-processing steps were used for the final substrate removal, this approach can fundamentally be extended to entirely wafer-scale processing, enabling future high-throughput fabrication of circuits containing thousands of phase shifters with minimal crosstalk and energy consumption.

Fig. 7a-b show the device cross-sections of standard (7a) and undercut (7b) thermal phase shifters with doped silicon wires on both sides of a silicon waveguide. Simulated performance for both designs (Fig. 7c-d) shows a dramatic increase in waveguide temperature in the undercut case for the same amount of dissipated power in the resistive heaters. The devices were fabricated in a commercial 300 mm foundry with air trenches etched at the wafer-scale on each side of the device, terminating at the buried oxide (BOX) under the silicon device layer (Fig. 7e). The chips were then postprocessed in a university cleanroom setting; first, the 2 μ m of BOX under the air trenches was removed using ICP RIE. Next, a vapor phase xenon diffouride (XeF_2) etch was used to isotropically remove the substrate in the air trenches and laterally undercut the device for full isolation (Fig. 7f). The thermal phase shifters were embedded in a balanced MZI structure to extract tuning efficiency from the interference fringes as a function of dissipated power. The undercut devices displayed a $P_{\pi} = 1.2$ mW (Fig. 7g), representing a $> 20 \times$ reduction compared to identical non-undercut designs and standard foundry process design kit (PDK) devices [40]. Due

to the thermal isolation, the fall time of the thermal response is greatly increased, corresponding to a reduction in the device S_{21} bandwidth compared to non-undercut designs (Fig. 7h). However, the thermal isolation increases both the response time for the integrated heater *and* the response time for ambient temperature fluctuations, so this reduction in S_{21} does not impact the efficacy of standard thermal control loops used to stabilize devices. Finally, we have closely collaborated with AIM Photonics to enable the full undercut design flow entirely in-line at the wafer scale, eliminating the post-processing requirements and permitting large-scale silicon photonic circuits with thousands to tens of thousands of highly efficient thermal phase shifters on a single chip.

C. Robustness to Fabrication Variations

Despite the efficiency gains realized through undercut heaters as described in the previous section, the required thermal tuning energy to correct for fabrication-induced phase errors still represents a large fraction of the link energy budget and prevents sub-pJ/bit operation. To address this issue, we propose and demonstrate a fabrication-robust platform in standard sub-micron silicon-on-insulator (SOI) processes, yielding devices with dramatically reduced sensitivity to fabrication variations [74]. Furthermore, these devices are fully compatible with substrate undercuts, illuminating a promising path to sub-100 μ W per device worst-case thermal power consumption. Our approach takes advantage of the well-known benefit of wide waveguides in terms of robustness to width variations, which are typically only used in straight sections of devices [75] due to wide waveguides supporting higherorder spatial modes which are easily excited in bends. In our

platform, we enable the use of wide waveguides for entire devices through carefully designing all bends for adiabaticity, employing Euler spirals which have a radius of curvature which varies linearly along the path [76]–[79]. The condition of adiabaticity minimizes mode mismatch interfaces through the bend and thus ensures that the $TE_0 \rightarrow TE_0$ transmission is maximized while $TE_0 \rightarrow TE_{1, 2, \dots, N}$ transmission is minimized, where N is the total number of supported modes. Using this methodology with 1.2 μ m wide waveguides, we demonstrate compact RMZI interleavers with state-ofthe-art performance and dramatically reduced sensitivity to fabrication variations [74]. We validate device performance for silicon devices fabricated using electron beam lithography in a university cleanroom setting as well as devices fabricated using deep ultra-violet (DUV) lithography in a 300 mm commercial foundry with excellent agreement between the two cases. Furthermore, we have recently taped out comprehensive DoE test structures on a dedicated 300 mm wafer run through AIM Photonics to collect comprehensive die-to-die, reticleto-recticle, and wafer-to-wafer statistics for waveguide widths ranging from 400 nm to 3 μ m. The concert of ultra-broadband performance, highly efficient undercut thermal phase shifters, and fabrication-robust design, all demonstrated on foundryfabricated wafers, will enable silicon photonic interleavers which meet the stringent performance and energy requirements for Tb/s/fiber and sub-pJ/bit operation.

V. RESONANT MODULATORS

While silicon photonic resonant modulators have been widely studied by both academia and industry due to their small footprint, high bandwidth, and energy efficiency, the stringent requirements of the interconnects proposed in this work severely restrict the available design space. In particular, the devices are required to achieve state-of-the-art performance in terms of extinction ratio and insertion loss while being driven by an EIC fabricated in a leading-edge CMOS process, which is typically supply voltage-limited to $V_{dd} < 1$ V. Furthermore, the devices must have a large FSR (> 20 nm) and must be capable of being fabricated in high volume at a commercial CMOS foundry. Vertical junction microdisk modulators have been demonstrated with performance capable of satisfying this list of requirements [44], [81], largely due to their low radiation loss at extremely small radii (< 5 μ m) and large overlap between the vertical junction and whispering gallery mode for standard 220 nm SOI processes. Furthermore, microdisk modulators possess a number of other favorable qualities compared to standard single-mode ring cavities, including reduced sensitivity to width variations. In this section, we explore the intricacies of the design and fabrication of microdisk modulators targeted for such systems, demonstrating a comprehensive design and simulation flow which closely matches experimental measurements from devices fabricated in a commercial 300 mm CMOS foundry.

A. Application-Specific Design Space

Resonant modulators have a notoriously large number of competing variables and design trade-offs which must be

balanced in an application-specific manner, including (but not limited to) resonance enhancement versus photon lifetime, carrier concentration versus round-trip loss, and mode overlap versus junction capacitance. For example, a high quality factor (Q) resonator will have a more narrow resonance dip (increased resonance enhancement) resulting in a large dynamic extinction ratio (ER) when the resonance is shifted, with the caveat that the time-domain behavior of light circulating in the cavity will restrict the achieveable modulation bandwidth [82]. The relation between optical and electrical bandwidth is given by [44]:

$$\left(\frac{1}{f_{3dB}^{el-opt}}\right)^2 = \left(\frac{1}{f_{3dB}^{opt}}\right)^2 + \left(\frac{1}{f_{3dB}^{el}}\right)^2 \tag{2}$$

where f_{3dB}^{el-opt} is the total electro-optic bandwidth, f_{3dB}^{opt} is the optical bandwidth (photon lifetime-limited bandwidth), and f_{3dB}^{el} is the electrical RC-limited bandwidth. From this relation, it is clear that a small optical bandwidth cannot be compensated by a large electrical bandwidth; for a particular target bandwidth, a corresponding reduction in Q is required regardless of improvements in the RC time constant.

Since the proposed link implementations focus on high parallelism with natively error-free performance at modest perchannel data rates (chosen for optimal energy efficiency and latency, discussed further in Section VI), the modulators do not need to support data rates higher than $\sim 20 \text{ Gb/s}/\lambda$. Due to this eased performance requirement, the photon lifetime limit on bandwidth is no longer as restrictive and thus higher Q modulators (Q $\sim 10,000$) with improved resonance enhancement can be considered. While high-Q modulators are permissible for these applications requiring modest data rates (5-20 Gb/s), additional care must be taken in the physical-level modeling to account for optical power handing considerations such as selfheating [83]. However, in the context of Kerr frequency combs for which the optical power per line can vary significantly, the low optical power of particular comb lines allows for selective modulator design in which each modulator can be individually tailored in an *a posteriori* manner to match the characteristics of the target comb line.

B. Carrier Profile

The vertical junction geometry is shown in Fig. 8a(ii), with n-doping in the top half of the waveguide and p-doping in the bottom half. Moderately doped p+ and n+ implants are used to reduce the series resistance and heavily doped p++ and n++ implants are used to form ohmic contacts between the silicon and metal vias [44]. Electrical carrier simulations were run using Ansys Lumerical CHARGE [84] to optimize the target carrier concentrations and maximize the change in depletion width with applied voltage (Fig. 8a(iii-iv)) while keeping the optical loss experienced by the mode in a moderate range (~ 30 dB/cm) such that the intrinsic cavity Q remains high.

For an abrupt p-n junction, the theoretical depletion width w_d is given by:

$$w_d = \sqrt{\frac{2\epsilon(N_D + N_A)(\phi_{bi} - V)}{qN_A N_D}}$$
(3)



Fig. 8. **a**, (i) Schematic overview of the microdisk modulator geometry and adjustable parameters. (ii) Device cross-section of the vertical junction and series/contact implants. (iii) Simulated 2D free carrier profile of the cross-section and 0 V and 1 V reverse bias with corresponding depletion widths. (iv) Simulated 1D slice of the junction profile. **b**, Difference in propagation constants of the symmetric and anti-symmetric supermodes of the disk-waveguide system as a function of waveguide width and gap (assuming concentric disk/coupler). The characteristic anti-crossing region indicating optimal phase matching is observed [80]. **c**, Representative plot of power coupling for the TE₀ and TE₁ modes as a function of coupler angle for the starred point from the anti-crossing region. The solid line at 2.5% indicates the critical coupling condition extracted from the simulated carrier-induced losses for the chosen implant conditions. The indicated design point is where TE₁ coupling is minimized and TE₀ is critically coupled. **d**, Modulator through-port spectrum from full 3D FDTD simulations including free carrier distribution profiles. **e**, Simulated modulation efficiency of the designed disk, indicating critical coupling and 67 pm shift of resonance for a 1 V reverse bias.

where ϵ is the permittivity of silicon, N_D is the donor dopant concentration, N_A is the acceptor dopant concentration, ϕ_{bi} is the built-in voltage, q is the elementary charge, and V is the applied bias. For silicon at 300 K with $N_D = N_A = 2.5 \times 10^{18}$ cm⁻³, $\phi_{bi} \approx 1$ V. From this, we can calculate the depletion width at zero bias for our vertical junction, yielding $w_d \sim 30$ nm, which agrees well with the TCAD simulated profile (Fig. 8a(iii)). The optimized 2D carrier concentration cross-sections were exported for electro-optic finite difference eigenmode (FDE) disk simulations in cylindrical coordinates using the well-known Soref and Bennett relations [85] (Ansys Lumerical MODE). Similarly, full 3D carrier simulations of the entire disk were run and exported for final electro-optic verification in 3D finite difference time domain (FDTD) simulations (Ansys Lumerical FDTD).

C. Mode-Selective Coupler

Microdisks are highly multimode systems and support a plethora of higher-order whispering gallery modes which can result in undesired spectral features leading to excess crosstalk and loss for non-target channels. To avoid exciting these higher-order modes and achieve an uncorrupted FSR, the coupler must be carefully designed to selectively excite the fundamental TE_0 mode close to critical coupling while transferring orders-of-magnitude less light from the bus into other modes. To achieve this, a radial pulley coupler is used to match the angular propagation constants of the symmetric and anti-symmetric supermodes of the disk-waveguide system for selective excitation of the fundamental TE_0 whispering gallery mode (Fig. 8a) [80]. First, an FDE solver is used to solve

for the angular propagation constants (APCs) of the disk and curved bus waveguide in isolation to narrow the design space. However, coupling the bus and disk perturbs these APCs and gives rise to symmetric and anti-symmetric supermodes of the waveguide-disk system. FDE sweeps of the coupled system for concentric configurations are then simulated to extract the APC difference between the symmetric and anti-symmetric supermodes, yielding an anti-crossing region for which there is good phase-matching and thus selective excitation of the fundamental TE₀ mode (Fig. 8b). Next, sampled disk-coupler configurations from this anti-crossing region were simulated using 3D FDTD for a range of coupler angles to identify designs where coupling into TE₀ is close to critical ($\sim 2.5\%$) while coupling into TE_1 is minimized (Fig. 8c). The critical coupling condition of 2.5% power coupling was extracted from the free carrier-induced loss for the target doping profile as described in the previous section.

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D. Electro-Optic Device Simulation

The full electro-optic performance of the device was simulated using two methods: (i) S-parameter-based circuit simulations (Ansys Lumerical INTERCONNECT) with exported carrier and mode results, and (ii) direct 3D FDTD simulations with exported 3D carrier profiles. S-parameter-based simulations were used to rapidly explore the electro-optic design space and create compact models for larger circuit-level simulations (eye diagram evaluation, bit error rate testing, etc.). The compact models consist of the exported 2D mode profile as a function of applied voltage (capturing the real and imaginary parts of $\Delta n_{eff}(V)$) and the exported coupler



Fig. 9. **a**, Device cross-section for the microdisk modulator integrated heater design. A 100 nm SiO_2 barrier is used to achieve full electrical isolation between the heater and junction. **b**, Annotated modulator layout. **c**, Microscope image of the fabricated device. **d**, Zoomed microscope image highlighting the visible isolation trench, verifying the integrity of the 100 nm full silicon etch used to separate the heater and junction.

S-parameters from FDTD, which are used to form a transfermatrix of the disk cavity to efficiently capture time-domain behavior [86]. Typically, high-Q resonant designs are difficult to simulate in FDTD since the simulation is computed in the time domain and convergence depends on the cavity photon lifetime. However, fully 3D electro-optic FDTD simulations are highly desirable to use as a final validation step for such designs, despite their high computational cost. Although the undoped silicon microdisks have extremely low material and radiation loss, the carrier-induced loss from the doping profile reduces the Q such that these simulations are viable to run on modern workstations for verification. The results for the 3D FDTD electro-optic simulations are shown in Fig. 8d-e, validating the design in terms of FSR (~ 24.5 nm), critical coupling condition, modulation efficiency ($\sim 67 \text{ pm/V}$), and higher-order mode suppression.

E. Integrated Heater

Doped silicon heaters, which are fabricated in the same silicon layer as the active and passive optical devices, require careful design as to not induce excessive optical loss while still maintaining close proximity to the optical mode for optimal thermo-optic efficiency. This design problem is additionally exacerbated in compact resonant modulators by the requirement of full electrical isolation between the heater and p-n junction used for carrier-depletion-based modulation. Previous designs have relied on engineering the intrinsic silicon region width between the heater and junction to increase the turn-on voltage of the parasitic p-i-n diodes that form such that they are never forward-biased into carrier injection under standard operating conditions [81], [87]. However, under realistic fabrication conditions, dopant diffusion and implant misalignment can significantly reduce the width of this intrinsic silicon



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Fig. 10. **a**, Measured spectrum of the fabricated device showing good agreement with simulation. All higher order modes are suppressed with 0.2 dB worst-case peak prominence while the fundamental TE₀ mode is near-critically coupled (> 16 dB ER). **b**, Measured response of the integrated heater. **c**, SEM images of devices prior to back-end-of-line processing where (i) is a single bus modulator and (ii) is an add-drop filter. **d**, Depletion response of the single bus modulator with applied reverse bias demonstrating a modulation efficiency of ~ 60 pm/V. **e**, Extinction ratio and insertion loss trade-off of the device as a function of peak-to-peak drive voltage (V_{pp}) and carrier detuning relative to the resonance center wavelength at $V_{bias} = 0$ V ($\Delta\lambda$).

region and thus result in highly undesirable electrical coupling between the heater and modulating diode.

We propose and demonstrate the use of a narrow silicon etch around an internal doped silicon heater in a compact microdisk modulator to provide full electrical isolation between the heater and the neighboring vertical junction p-n diode (Fig. 9) [88]. By introducing a 100 nm SiO₂ barrier between the heater and diode, we observe complete electrical isolation in both simulation and experiment with minimal degradation in thermo-optic efficiency. Furthermore, this degradation in efficiency can be made nearly negligible through the use of a selective substrate undercut similar to that described in Section IV [89]. This isolated heater enables reliable and fabricationrobust thermally-tunable microdisk modulators while maintaining a compact footprint and large FSR.

F. Experimental Characterization

The six new vertical junction implants, including series link and contact implants, were co-designed in collaboration with a commercial 300 mm foundry (AIM Photonics) to optimize doping conditions (implantation energy, dose, species, etc.). Doping quadrants were run across multiple wafers to optimize implant conditions and fully explore the electrooptic performance dependence on carrier concentration above and below the target design point. The design of experiment (DoE) devices were taped out in a dedicated wafer run and experimentally validated against simulation models, showing

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good agreement in key metrics including FSR, higher-order mode suppression, critical coupling condition, and thermal tuning efficiency (Fig. 10a-b). Scanning electron microscope (SEM) images of the devices prior to back-end-of-line (BEOL) processing were used to verify the integrity of the full silicon etch around the integrated heater and gap width between the bus and disk for both single bus and add-drop designs (Fig. 10c). The experimentally measured depletion response (60 pm/V, Fig. 10d) closely matches the electro-optic 3D FDTD simulations (67 pm/V, Fig. 8e), validating the design and simulation workflow. Finally, due to the high-Q design for moderate data rates, the devices can achieve large extinction ratio and low insertion loss operation for CMOS-compatible drive voltages (Fig. 10e).

VI. ENERGY EFFICIENCY CONSIDERATIONS

While a comprehensive analysis of the link energy efficiency trade-offs is beyond the scope of this work (see [90] and [91] for extended discussions), the device and system design choices outlined here are heavily influenced by general considerations regarding the energy consumption of highspeed electronic-photonic data communication links. In this section, we briefly discuss these considerations for all sources of energy consumption in our architecture and evaluate the requisite system characteristics necessary to achieve sub-pJ/bit operation.

A. Modulation Format, Data Rate, and Bit-Error Rate

While coherent communications (encoding information in the phase of light) can provide significantly more channel bandwidth than intensity modulated direct-detection (IM-DD) schemes, this increase comes at a cost in terms of latency and energy consumption. In particular, modest data rate IM-DD signaling with a native bit error rate (BER) below 10⁻¹² provides ideal latency and energy efficiency characteristics since it removes the need for power-hungry digital signal processing (DSP) and forward error correction (FEC). Such signaling is typically infeasible for standard single or quad channel links due to the low aggregate bandwidth; however, in the proposed massively parallel WDM links, Tb/s/fiber aggregate bandwidth is achievable with modest data rates on the order of 10-20 Gb/s/ λ . This wide-parallel approach keeps the signal format close to that of intra-die compute node signaling, reducing the need for DSP and (de-)serialization which in turn reduces latency and energy consumption.

B. Comb Source

Since Kerr combs rely on a CW pump to generate the comb, the total efficiency is determined by the wall-plug efficiency (WPE) of the pump *and* the pump-to-comb conversion efficiency of the microresonators. For this reason, it is critically important for both efficiencies to be large such that their product represents reasonable conversion from electricity to usable optical carriers. Pump conversion into unusable comb lines below the link budget can significantly degrade the overall system wall-plug efficiency and thus conversion should be spectrally confined to the bandwidth of interest with sharp roll-off beyond the band edges [92]. In this direction, we are pursuing synchronized Kerr combs [65], [93] possessing different spectral envelopes which are then coherently combined to boost and equalize the line powers. Furthermore, normal GVD Kerr combs exhibit inherently high pump-tocomb efficiencies (> 40%) which can be confined to a target spectral window and high power distributed feedback (DFB) lasers have been demonstrated with 35% WPE and output powers high enough for comb generation (~ 200 mW) [94].

C. Modulators

Carrier-depletion-based resonant modulators (assumed to be a lumped-element, i.e. device size $\langle \lambda_{RF} \rangle$) act as a capacitive load which must be charged and discharged by the analog electronic driver. In contrast to carrier-injection modulators, no current flows under standard device operation and thus the only energy consumption is the switching energy associated with $0 \rightarrow 1$ transitions in the NRZ bit sequence ($E_b = \frac{1}{4}CV^2$ where E_b is the energy per bit). Highly efficient vertical junction microdisk modulators with low peak-to-peak drive voltage have been shown to consume as low as $E_b = 1$ fJ [44] and thus do not contribute significantly to the total link energy.

D. Thermal Tuning

Thermal tuning of devices to correct for fabrication-induced phase errors and environmental temperature swings has been shown to be a dominant source of energy consumption in resonator-based silicon photonic systems subjected to copackaged thermal environments [37]. The undercut thermal phase shifters and fabrication-robust design methodology discussed in Section IV can significantly decrease this source of energy consumption. Furthermore, other promising strategies for reducing thermal tuning power have been demonstrated in the silicon photonics platform, including post-fabrication trimming to near-perfectly correct for fabrication variations [95] and negative thermo-optic coefficient cladding designed to neutralize the strong thermo-optic effect in silicon [96]. However, both of these approaches require significant changes to the fabrication process, and trimming inherently reduces throughput since it requires post-processing of individual devices across the entire wafer.

E. Clock Distribution

Significant energy can be saved through using one of the comb WDM channels for clock forwarding since electronic clocking with digital phase-locked loops (PLLs) has been shown to be a dominant source of energy consumption in silicon photonic links [30]. As normal GVD Kerr combs have been shown to be capable of providing on the order of > 100 wavelength channels, the opportunity cost of the bandwidth gain associated with using one extra wavelength for data communications is far outweighed by the energy efficiency of using the same wavelength for clock forwarding [90].

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Fig. 11. **a**, Experimental setup for the comb-driven integrated receiver demonstration. CW TLS: continuous wave tunable laser source, EDFA: erbium-doped fiber amplifier, MZI: Mach Zehnder interferometer, VOA: variable optical attenuator, BERT: bit-error rate tester. **b**, Microscope image of the resonant filter and epitaxial germanium photodetector. **c**, Through-port spectral response of the resonant filters aligned to adjacent comb lines. **d**, Measured eye diagrams for each received modulated comb line while all channels are running simultaneously at 16 Gb/s/ λ .

F. Packaging Parasitics

Parasitic resistance, capacitance, and inductance associated with interfaces between electronic and photonic devices (wirebonds, C4 solder bumps, copper pillars, etc.) can significantly degrade performance and must be considered in the overall system analysis. For this reason, we employ flip-chip bonding with copper pillar microbumps to form the connections between analog electronic drivers and photonic devices, creating a short electrical signal path with low parasitics. While monolithic integration provides the lowest parasitic connections between electronics and photonics (intra-chip BEOL metal traces), this gain is offset by the inability to leverage leadingedge process node transistors and thus has a significant impact on the energy consumption of the analog electronic circuits.

G. Aggregate Energy Efficiency Assumptions

In all reported energy efficiency numbers throughout this work, our analysis includes all sources beginning with an onchip pseudo-random bit sequence (PRBS) generator in the flip-chipped CMOS ASIC proxy core and terminating at an on-chip BER checker on the same CMOS die. Therefore, the power consumption of all other electronic and photonic devices/circuits in the total signal path between the PRBS generation and checking are considered, including the copper pillar interconnects, electronic control circuits, and analog driving electronics. All electronic circuits are designed in the TSMC 28 nm process node.

VII. SYSTEM-LEVEL DEMONSTRATIONS

In this section, we detail comprehensive experimental demonstrations showing proof-of-principle operation for massively parallel silicon photonic links driven by Kerr frequency comb sources. Furthermore, we show dense heterogeneous integration between foundry-fabricated CMOS electronic and photonic chips, providing a platform for full system-level demonstrations of the proposed interconnect architecture.

A. Integrated Transmitter

We have successfully demonstrated error-free operation with a normal-GVD Kerr comb source and silicon photonic transmitter up to 16 Gb/s/ λ for both single bus [23] and evenodd interleaved architectures [22], [24], with channel counts of 20 and 32, respectively. Furthermore, we have recently shown simultaneous modulation of adjacent comb lines at 200 GHz spacing on the same bus, achieving error-free operation for both channels with negligible crosstalk [97]. These initial proof-of-principle data transmission experiments were limited to 32 channels for a variety of pragmatic testing considerations including device insertion losses, packaging limitations, and the number of high-SNR comb lines generated in available fabricated devices. Through the previously detailed improvements of the photonic devices. Kerr combs, and packaging, future demonstrations will not have this restriction on channel count (see Appendix I). These experimental demonstrations validate the feasibility of the proposed architecture and approach, representing the first work of its kind showing WDM data transmission using active silicon photonic circuits with Kerr frequency comb sources.

B. Integrated Receiver

We demonstrated an experimental comb-driven receiver, shown in Fig. 11 and reported in [98], for evaluating the performance of receiving multiple comb lines with a PIC. Three comb lines at 1556.7, 1558.3, and 1559.9 nm are filtered from a Kerr comb source and modulated with a Mach Zehnder modulator at 16 Gb/s. Each data channel is offset by 0.5 unit intervals using 1.25 km of SMF-28 fiber and subsequently coupled into the PIC receiver chip. The PIC receiver drops the signals from a common bus with aligned ring filters to vertical p-i-n germanium photodiodes with 1.1 A/W responsivity, nearing the maximum quantum efficiency of 1.25 A/W responsivity in the C band [99]. A microscope image of the filter and photodiode is shown in Fig. 11b and the

aligned filter spectrum is shown in Fig. 11c. The photodiodes were electrically probed with a 50 Ω S-G RF probe and reverse biased 2.5 V using a bias-T to minimize carrier transit time. A coaxial cable connects the probe to a real time oscilloscope with 50 Ω termination, giving a 50 Ω transimpedance gain and yielding the resulting eye diagrams in Fig. 11d. The resulting received data was error-free at -2 dBm input power as measured with the DC current of the bias-T. The receiver demonstration was limited to three wavelengths due to the saturation output power of the EDFAs used in the experiment; the gain was saturated by the higher power lines and would not permit more lines at lower power into the system. A higher transimpedance gain, removal of the 1.25 km fiber spool, and closer integration with CMOS TIAs are expected to lower the required power for error-free reception.

C. 3D Heterogeneous Integration with CMOS Electronics

Silicon photonic devices can be arranged within a micron of each other due to the high index contrast between silicon and SiO₂. This vast potential for bandwidth density is constrained in applications by the packaging of the system. The foremost issue is integration of photonics and electronics. Photonic and CMOS devices may be monolithically integrated on the same die and connected with the wiring density of CMOS BEOL [30], [100]. Alternatively, 3D integration with flipchip bonding places the EIC circuits on its own die, saving space and allowing for leading edge CMOS nodes with higher transistor density and performance [101]. In a 3D integrated transceiver, the density is limited by the connection pitch between the photonic and electronic die.

As a trial of dense 3D integration with low parasitics, we connected a CMOS EIC (TSMC 28 nm node) and photonic chip with solder-tipped copper pillar bumps at a 25 μ m pitch (Fig. 12). The electronic and photonic chips are fabricated with arrays of aluminum terminated pads. In post-processing, these pads are plated with under-bump metallization, and copper pillar microbumps are fabricated on the EIC. A microscope image of the bumps is shown in Fig. 12c. The EIC is then flipped onto the PIC, with power and control signals delivered to the EIC by traces on the PIC wirebonded to a PCB. The combined die are shown in Fig. 12b. In this packaging platform, a link is designed with two stages of even-odd interleavers feeding four buses of 16 microdisks for transmit and ring filters to photodiodes for receive. The transmitter and receiver cells are 25 μ m \times 75 μ m with three inter-chip connections: high speed signal, ground, and heater control signal. The footprint of the 64 channel system fits into a 0.4 mm² area, yielding a bandwidth density of 5 Tb/s/mm² when operating at 16 Gb/s/ λ . A microscope image of the system is shown in Fig. 12e. Scaling up this demonstration or co-packaging the transceiver would require replacing the wirebonds on the periphery of the PIC with through silicon via (TSV) connections on its back side.

Given the demonstrated areal bandwidth density of 5 Tb/s/mm² and a standard 300 mm wafer reticle-limited die size of $\sim 625 \text{ mm}^2$, this platform could conceivably support 3.125 Pb/s package escape bandwidth. However, while densely



Fig. 12. **a**, Image of the fabricated and packaged multi-chip module (MCM) system with the electronic integrated circuit (EIC) flip-chip bonded to the photonic integrated circuit (PIC) using copper pillar microbumps. **b**, Schematic of the copper pillar interconnect material stack. **c**, Microscope image of the MCM photonic circuit with two stages of (de-)interleaving, 64 resonant modulators, and 64 resonant filters within a total footprint of 0.4 mm². **d**, Microscope image of the plated and densely bumped chip at 25 μ m pitch.

bumped flip-chip packaging would scale trivially to accommodate the larger die size, optical I/O presents a bottleneck. Assuming the previously detailed 1 Tb/s/fiber bandwidth, the package would require 1,000 optical connections for Pb/s operation. Again assuming a reticle-limited die edge length of 25 mm with edge couplers at 127 μ m pitch, each side would be limited to 196 connections and thus could only provide 784 total optical ports. However, using widely available reduced cladding fibers with 80 μ m diameter [102], each side could support 312 connections and thus conceivably permit Pb/sscale operation on a single chip.

D. Future Demonstrations

We have recently taped out a dedicated 300 mm wafer through AIM Photonics with various device- and system-level iterations improving on those described in this work (Fig. 13). Most notably, dedicated wafer fabrication (compared to singulated MPW die) will enable wafer-scale bumping and flip-chip bonding for more reliable and higher-yield packaging with CMOS electronics. Furthermore, the system-level circuit iterations taped out on this run include a combination of the device-level advances described in this work, including highly efficient microdisk modulators, undercut thermal phase shifters (for all thermally tuned devices), fabrication-robust interleavers, and floating edge couplers with sub-dB fiber-to-



Fig. 13. Reticle layout for dedicated 300 mm wafer taped out through AIM Photonics in November 2021. Various MCM iterations leveraging the device advances outlined in this work are laid out for wafer-scale bumping and flip-chip packaging.

chip loss for standard SMF-28 fiber. The MCM circuits on this wafer leverage all of the previously mentioned device advances and target an optical amplifier-free 64 channel system capable of achieving 0.5 pJ/bit energy efficiency with 1.024 Tb/s/fiber aggregate bandwidth and 5 Tb/s/mm² areal bandwidth density. Through building a fully developed application-specific device library in a single foundry platform, unprecedented design complexity and performance can be achieved to meet the stringent metrics required for future Pb/s and sub-pJ/bit interconnect operation.

VIII. SUMMARY AND OUTLOOK

In this work, we have provided a comprehensive overview of massively parallel WDM optical interconnects based on integrated Kerr frequency combs and silicon photonic circuits. We detail the full link design hierarchy, including fundamental device design, circuit-level design considerations, and co-design of heterogeneously-integrated electronic-photonic systems. To support these design conclusions, we present a wide variety of representative results from simulation and experiment at each step of the hierarchy including numerous novel device and system demonstrations. While the work described here focused exclusively on extreme scaling in the wavelength domain, we have recently demonstrated a mode-division multiplexing (MDM) interface between silicon photonic chips and fewmode fiber [103], [104], leveraging the spatial mode domain as an orthogonal axis for multiplicative WDM and MDM scaling. Various WDM-compatible MDM architectures have been demonstrated in the silicon photonics platform [25], [105], which can be trivially extended to accommodate the WDM architectures described in this work. Achieving Pb/s package escape bandwidths will be crucial for continued scaling of computing systems to keep pace with exponentially growing demand over the next quarter century and beyond.

APPENDIX I: OPTICAL LINK BUDGET

In this Appendix, we present an analytical model for the optical link budget to demonstrate the scalability of the proposed massively parallel architecture. As an example, we consider an implementation driven by a 64 channel comb with 150 GHz channel spacing. To achieve Tb/s aggregate bandwidth per fiber while maintaining low single-channel NRZ data rates, we assume a single channel data rate of 16 Gb/s/ λ . Using two stages of even-odd interleaving, as illustrated in Fig. 2c, the initial 150 GHz-spaced comb is subdivided into four parallel buses, each with 16 channels at 600 GHz spacing. There are several sources of optical loss to be considered in such an architecture, which can be split among two main categories: bandwidth-dependent device IL and signal power penalties. The total optical link penalty is the sum of these two parts.

Bandwidth-Dependent Device IL

For coupling light on to and off of each chip, we use edge couplers rather than grating couplers due to their broadband low-loss performance. Previous state of the art demonstrations for silicon photonic edge couplers have shown broadband coupling efficiency ≤ 1 dB [106]. Limiting our scope to edge couplers that are compatible with the same fabrication processes as the rest of our devices, we estimate the per facet IL to be 1 dB. The link architecture uses a total of six RAMZIs performing even-odd interleaving to multiplex and de-multiplex the comb lines. To model the bandwidth dependent loss of the devices, we measured the transmission spectra on one of our test chips and fit a polynomial curve to the peaks. The 64 channel 150 GHz comb covers approximately 73 nm of optical bandwidth, corresponding to ~ 0.7 dB IL per RAMZI.

For the 16 channel resonator arrays, two sources of device IL are considered: on- and off-resonance IL. For the modulators and filters on-resonance IL as low as 1 dB and 0.2 dB have been demonstrated respectively [40], [44]. For off-resonance IL, we have measured as low as 0.05 dB per device. Finally, the long on-chip routing results in non-negligible waveguide propagation loss, which we assume to be ~ 1 dB/cm from reported foundry measurements [40]. We assume roughly 3.5 mm of waveguide routing between the transmitter and receiver, dominated by device electrical pad pitch.

Signal Power Penalties

The wide-parallel approach, using the lowest-order IM-DD format of non-return-to-zero on-off keying (NRZ-OOK), removes the need for power-consuming and latency-inducing DSP and FEC, but also introduces an inherent power penalty dependent on the signal extinction ratio (ER). The penalty can be calculated as

$$PP_{ER/OOK} = PP_{ER} + PP_{OOK}$$
$$= -10 \log_{10} \left(\frac{r-1}{r+1}\right)$$
$$-10 \log_{10} \left(\frac{r+1}{2r}\right)$$

Where $r = 10^{ER/10}$ and ER is the logarithmic extinction ratio between the optical power of a '1' and a '0', in units of dB. Fig. 14a plots the individual components and total

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 TABLE I

 Sum of total insertion losses and power penalties in the proposed 1.024 Tb/s link.

| Transmitter | | | |
|-----------------------|---------------------|---------------------------|-----------------------|
| Coupler IL [dB] | Interleaver IL [dB] | Modulator Array IL [dB] | Signal Penalties [dB] |
| 3 | 2.80 | 1.75 | 3.75 |
| | | | |
| Receiver | | | |
| Coupler IL [dB] | Interleaver IL [dB] | Ring Filter Array IL [dB] | |
| 1 | 1.4 | 0.95 | |
| | | | |
| Propagation Loss [dB] | Tx Total [dB] | Rx Total [dB] | Total [dB] |
| 0.35 | 11.3 | 3.35 | 15 |

 $PP_{ER/OOK}$ as a function of ER, showing that for a perfect, infinite ER, the penalty converges to 3 dB (as a result of average power of the signal being half the input laser power for a data pattern with an equal distribution of '1's and '0's). Fig. 14b shows the derivative of modulation power penalty with respect to ER, emphasizing the diminishing returns in pursuing an $ER \ge 10$ dB.



Fig. 14. **a**, Total and component parts of $PP_{ER/OOK}$ as a function of ER. **b**, Derivative of $PP_{ER/OOK}$ with respect to ER.

As illustrated in Fig. 10e, the device IL and ER of resonant modulators are inherently coupled, along with the electrical driving signal V_{pp} . For the purposes of this analysis, we use the IL and ER values demonstrated in [44], where $IL \sim 1$ dB and $ER \sim 8$ dB at data rates near 16 Gb/s with a CMOS compatible V_{pp} .

Inter-channel cross-talk limits can contribute substantial power penalties in WDM links, particularly if the channel spacing is made small. It has been demonstrated that for cascaded resonator-based WDM links, these penalties can be considered negligible (≤ 0.1 dB) when $\lambda_{ag} \geq 150$ GHz [39]. While a link operating across a single resonator FSR would be fundamentally limited, we can instead operate in the multiFSR regime, and refer to Fig. 4c for a selection of resonator FSR for a 16 channel 600 GHz-spaced WDM bus. It is clear that a resonator FSR between 25 and 30 nm, corresponding to a disk radius between 3.6 μ m and 4.5 μ m, satisfies the λ_{ag} constraint.

Finally, the bandwidth of the resonant filter at the receiver can introduce signal distortion, but has also been demonstrated as optically equalizing and mitigating pulse width distortion provided the Q-factor of the filter is designed so that the Lorentzian full-width half-max is approximately twice the channel data rate [107]. Pending further work on this topic, we do not attribute any positive or negative (an improvement in signal quality) penalty to the resonant filter spectral distortion effects.

Total Optical Link Budget

Present in the transmitter are 3 edge couplers, 4 RAMZI filter stages, 1 on-resonance and 15 off-resonance modulators per channel, and the modulation signal penalty. On the receiver side there is 1 edge coupler, 2 RAMZI filter stages, and similarly 1 on-resonance and 15 off-resonance filters per channel. The total link penalty is summarized in Table I.

Using state-of-the-art receiver designs we estimate a receiver sensitivity threshold of ≤ -19 dBm at a channel data rate of 16 Gb/s [108]. Adding the estimated total optical link penalty, this results in a minimum optical power per line of -4 dBm to satisfy native error-free link performance.

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REFERENCES

- D. A. B. Miller, "Rationale and challenges for optical interconnects to electronic chips," *Proceedings of the IEEE*, vol. 88, no. 6, pp. 728–749, 2000.
- [2] D. A. B. Miller, "Device requirements for optical interconnects to silicon chips," *Proceedings of the IEEE*, vol. 97, no. 7, pp. 1166–1185, 2009.
- [3] Q. Cheng, M. Bahadori, M. Glick, S. Rumley, and K. Bergman, "Recent advances in optical technologies for data centers: a review," *Optica*, vol. 5, no. 11, pp. 1354–1370, Nov 2018.
- [4] T. Udem, R. Holzwarth, and T. W. Hänsch, "Optical frequency metrology," *Nature*, vol. 416, no. 6877, pp. 233–237, Mar 2002.
- [5] D. J. Jones, S. A. Diddams, J. K. Ranka, A. Stentz, R. S. Windeler, J. L. Hall, and S. T. Cundiff, "Carrier-envelope phase control of femtosecond mode-locked lasers and direct optical frequency synthesis," *Science*, vol. 288, no. 5466, pp. 635–639, 2000.
- [6] J. L. Hall, "Nobel lecture: Defining and measuring optical frequencies," *Rev. Mod. Phys.*, vol. 78, pp. 1279–1295, Nov 2006.
- [7] P. Del'Haye, A. Schliesser, O. Arcizet, T. Wilken, R. Holzwarth, and T. J. Kippenberg, "Optical frequency comb generation from a monolithic microresonator," *Nature*, vol. 450, no. 7173, pp. 1214–1217, Dec 2007.
- [8] J. S. Levy, A. Gondarenko, M. A. Foster, A. C. Turner-Foster, A. L. Gaeta, and M. Lipson, "Cmos-compatible multiple-wavelength oscillator for on-chip optical interconnects," *Nature Photonics*, vol. 4, no. 1, pp. 37–40, Jan 2010.
- [9] T. J. Kippenberg, A. L. Gaeta, M. Lipson, and M. L. Gorodetsky, "Dissipative kerr solitons in optical microresonators," *Science*, vol. 361, no. 6402, 2018.
- [10] A. L. Gaeta, M. Lipson, and T. J. Kippenberg, "Photonic-chip-based frequency combs," *Nature Photonics*, vol. 13, no. 3, pp. 158–169, Mar 2019.
- [11] M.-G. Suh and K. J. Vahala, "Soliton microcomb range measurement," *Science*, vol. 359, no. 6378, pp. 884–887, 2018.
- [12] D. T. Spencer, T. Drake, T. C. Briles, J. Stone, L. C. Sinclair, C. Fredrick, Q. Li, D. Westly, B. R. Ilic, A. Bluestone, N. Volet, T. Komljenovic, L. Chang, S. H. Lee, D. Y. Oh, M.-G. Suh, K. Y. Yang, M. H. P. Pfeiffer, T. J. Kippenberg, E. Norberg, L. Theogarajan, K. Vahala, N. R. Newbury, K. Srinivasan, J. E. Bowers, S. A. Diddams, and S. B. Papp, "An optical-frequency synthesizer using integrated photonics," *Nature*, vol. 557, no. 7703, pp. 81–85, May 2018.
- [13] M. Kues, C. Reimer, J. M. Lukens, W. J. Munro, A. M. Weiner, D. J. Moss, and R. Morandotti, "Quantum optical microcombs," *Nature Photonics*, vol. 13, no. 3, pp. 170–179, Mar 2019.
- [14] M.-G. Suh, Q.-F. Yang, K. Y. Yang, X. Yi, and K. J. Vahala, "Microresonator soliton dual-comb spectroscopy," *Science*, vol. 354, no. 6312, pp. 600–603, 2016.
- [15] M. Yu, Y. Okawachi, A. G. Griffith, N. Picqué, M. Lipson, and A. L. Gaeta, "Silicon-chip-based mid-infrared dual-comb spectroscopy," *Nature Communications*, vol. 9, no. 1, p. 1869, May 2018.
- [16] P. Marin-Palomo, J. N. Kemal, M. Karpov, A. Kordts, J. Pfeifle, M. H. P. Pfeiffer, P. Trocha, S. Wolf, V. Brasch, M. H. Anderson, R. Rosenberger, K. Vijayan, W. Freude, T. J. Kippenberg, and C. Koos, "Microresonator-based solitons for massively parallel coherent optical communications," *Nature*, vol. 546, no. 7657, pp. 274–279, Jun 2017.
- [17] B. Corcoran *et al.*, "Ultra-dense optical data transmission over standard fibre with a single chip source," *Nature Communications*, vol. 11, no. 1, p. 2568, May 2020.
- [18] A. Fülöp et al., "High-order coherent communications using modelocked dark-pulse kerr combs from microresonators," *Nature Commu*nications, vol. 9, no. 1, p. 1598, Apr 2018.
- [19] H. Hu, F. Da Ros, M. Pu, F. Ye, K. Ingerslev, E. Porto da Silva, M. Nooruzzaman, Y. Amma, Y. Sasaki, T. Mizuno, Y. Miyamoto, L. Ottaviano, E. Semenova, P. Guan, D. Zibar, M. Galili, K. Yvind, T. Morioka, and L. K. Oxenløwe, "Single-source chip-based frequency comb enabling extreme parallel data transmission," *Nature Photonics*, vol. 12, no. 8, pp. 469–473, Aug 2018.
- [20] H. Hu and L. K. Oxenløwe, "Chip-based optical frequency combs for high-capacity optical communications," *Nanophotonics*, vol. 10, no. 5, pp. 1367–1385, 2021. [Online]. Available: https://doi.org/10.1515/nanoph-2020-0561
- [21] J. Pfeifle, V. Brasch, M. Lauermann, Y. Yu, D. Wegner, T. Herr, K. Hartinger, P. Schindler, J. Li, D. Hillerkuss, R. Schmogrow, C. Weimann, R. Holzwarth, W. Freude, J. Leuthold, T. J. Kippenberg, and C. Koos, "Coherent terabit communications with microresonator

kerr frequency combs," Nature Photonics, vol. 8, no. 5, pp. 375-380, May 2014.

- [22] A. Rizzo et al., "Kerr comb-driven silicon photonic transmitter," in Optical Fiber Communication Conference (OFC) 2021. Optical Society of America, 2021, p. Th4A.5.
- [23] A. Novick *et al.*, "Error-free kerr comb-driven sip microdisk transmitter," in 2021 Conference on Lasers and Electro-Optics (CLEO), 2021, pp. 1–2.
- [24] A. Rizzo et al., "Integrated kerr frequency comb-driven silicon photonic transmitter," arXiv:2109.10297, 2021.
- [25] K. Y. Yang, A. D. White, F. Ashtiani, C. Shirpurkar, S. V. Pericherla, L. Chang, H. Song, K. Zou, H. Zhou, K. Pang *et al.*, "Inverse-designed multi-dimensional silicon photonic transmitters," *arXiv preprint arXiv:2103.14139*, 2021.
- [26] C. Li, H. Zhang, G. Zhou, L. Lu, M. Jin, J. Dong, L. Zhou, and J. Chen, "Hybrid wdm-mdm transmitter with an integrated si modulator array and a micro-resonator comb source," *Opt. Express*, vol. 29, no. 24, pp. 39 847–39 858, Nov 2021.
- [27] B. Stern, X. Ji, Y. Okawachi, A. L. Gaeta, and M. Lipson, "Batteryoperated integrated frequency comb generator," *Nature*, vol. 562, no. 7727, pp. 401–405, Oct 2018.
- [28] B. Shen, L. Chang, J. Liu, H. Wang, Q.-F. Yang, C. Xiang, R. N. Wang, J. He, T. Liu, W. Xie, J. Guo, D. Kinghorn, L. Wu, Q.-X. Ji, T. J. Kippenberg, K. Vahala, and J. E. Bowers, "Integrated turnkey soliton microcombs," *Nature*, vol. 582, no. 7812, pp. 365–369, Jun 2020.
- [29] C. Wang, M. Zhang, M. Yu, R. Zhu, H. Hu, and M. Loncar, "Monolithic lithium niobate photonic circuits for kerr frequency comb generation and modulation," *Nature Communications*, vol. 10, no. 1, p. 978, Feb 2019.
- [30] M. Wade et al., "An error-free 1 tbps wdm optical i/o chiplet and multi-wavelength multi-port laser," in Optical Fiber Communication Conference (OFC) 2021. Optical Society of America, 2021, p. F3C.6.
- [31] M. Glick, N. C. Abrams, Q. Cheng, M. Y. Teh, Y.-H. Hung, O. Jimenez, S. Liu, Y. Okawachi, X. Meng, L. Johansson *et al.*, "Pine: photonic integrated networked energy efficient datacenters (enlitened program)," *Journal of Optical Communications and Networking*, vol. 12, no. 12, pp. 443–456, 2020.
- [32] M. Khani, M. Ghobadi, M. Alizadeh, Z. Zhu, M. Glick, K. Bergman, A. Vahdat, B. Klenk, and E. Ebrahimi, "Sip-ml: high-bandwidth optical network interconnects for machine learning training," in *Proceedings* of the 2021 ACM SIGCOMM 2021 Conference, 2021, pp. 657–675.
- [33] G. Michelogiannakis, Y. Shen, M. Y. Teh, X. Meng, B. Aivazi, T. Groves, J. Shalf, M. Glick, M. Ghobadi, L. Dennison et al., "Bandwidth steering in hpc using silicon nanophotonics," in *Proceedings* of the International Conference for High Performance Computing, Networking, Storage and Analysis, 2019, pp. 1–25.
- [34] Y. Shen, X. Meng, Q. Cheng, S. Rumley, N. Abrams, A. Gazman, E. Manzhosov, M. S. Glick, and K. Bergman, "Silicon photonics for extreme scale systems," *Journal of Lightwave Technology*, vol. 37, no. 2, pp. 245–259, 2019.
- [35] Q. Xu, B. Schmidt, J. Shakya, and M. Lipson, "Cascaded silicon micro-ring modulators for wdm optical interconnection," *Opt. Express*, vol. 14, no. 20, pp. 9431–9436, Oct 2006.
- [36] C.-H. Chen, M. A. Seyedi, M. Fiorentino, D. Livshits, A. Gubenko, S. Mikhrin, V. Mikhrin, and R. G. Beausoleil, "A comb laser-driven dwdm silicon photonic transmitter based on microring modulators," *Opt. Express*, vol. 23, no. 16, pp. 21 541–21 548, Aug 2015.
- [37] Y. London, T. Van Vaerenbergh, A. J. Rizzo, P. Sun, J. Hulme, G. Kurczveil, A. Seyedi, B. Wang, X. Zeng, Z. Huang, J. Rhim, M. Fiorentino, and K. Bergman, "Energy efficiency analysis of comb source carrier-injection ring-based silicon photonic link," *IEEE Journal* of Selected Topics in Quantum Electronics, vol. 26, no. 2, pp. 1–13, 2020.
- [38] Y. London, T. V. Vaerenbergh, L. Ramini, A. J. Rizzo, P. Sun, G. Kurczveil, A. Seyedi, J. Rhim, M. Fiorentino, and K. Bergman, "Performance requirements for terabit-class silicon photonic links based on cascaded microring resonators," *J. Lightwave Technol.*, vol. 38, no. 13, pp. 3469–3477, Jul 2020.
- [39] K. Padmaraju, X. Zhu, L. Chen, M. Lipson, and K. Bergman, "Intermodulation crosstalk characteristics of wdm silicon microring modulators," *IEEE Photonics Technology Letters*, vol. 26, no. 14, pp. 1478–1481, 2014.
- [40] N. M. Fahrenkopf, C. McDonough, G. L. Leake, Z. Su, E. Timurdogan, and D. D. Coolbaugh, "The aim photonics mpw: A highly accessible cutting edge technology for rapid prototyping of photonic integrated

circuits," IEEE Journal of Selected Topics in Quantum Electronics, vol. 25, no. 5, pp. 1–6, 2019.

- [41] E. Timurdogan, C. M. Sorace-Agaskar, E. S. Hosseini, and M. R. Watts, "An interior-ridge silicon microring modulator," *Journal of lightwave technology*, vol. 31, no. 24, pp. 3907–3914, 2013.
- [42] M. Gehl, C. Long, D. Trotter, A. Starbuck, A. Pomerene, J. B. Wright, S. Melgaard, J. Siirola, A. L. Lentine, and C. DeRose, "Operation of high-speed silicon photonic micro-disk modulators at cryogenic temperatures," *Optica*, vol. 4, no. 3, pp. 374–382, 2017.
- [43] H. Gevorgyan, A. Khilo, M. T. Wade, V. M. Stojanović, and M. A. Popović, "Miniature, highly sensitive moscap ring modulators in cooptimized electronic-photonic cmos," *Photonics Research*, vol. 10, no. 1, pp. A1–A7, 2022.
- [44] E. Timurdogan, C. M. Sorace-Agaskar, J. Sun, E. Shah Hosseini, A. Biberman, and M. R. Watts, "An ultralow power athermal silicon modulator," *Nature Communications*, vol. 5, no. 1, p. 4008, Jun 2014.
- [45] A. Rizzo, Q. Cheng, S. Daudlin, and K. Bergman, "Ultra-broadband interleaver for extreme wavelength scaling in silicon photonic links," *IEEE Photonics Technology Letters*, vol. 33, no. 1, pp. 55–58, 2021.
- [46] L.-W. Luo, S. Ibrahim, A. Nitkowski, Z. Ding, C. B. Poitras, S. J. B. Yoo, and M. Lipson, "High bandwidth on-chip silicon photonic interleaver," *Opt. Express*, vol. 18, no. 22, pp. 23 079–23 087, Oct 2010.
- [47] F. Horst, W. M. Green, S. Assefa, S. M. Shank, Y. A. Vlasov, and B. J. Offrein, "Cascaded mach-zehnder wavelength filters in silicon photonics for low loss and flat pass-band wdm (de-) multiplexing," *Optics express*, vol. 21, no. 10, pp. 11 652–11 658, 2013.
- [48] E. S. Magden, N. Li, M. Raval, C. V. Poulton, A. Ruocco, N. Singh, D. Vermeulen, E. P. Ippen, L. A. Kolodziejski, and M. R. Watts, "Transmissive silicon photonic dichroic filters with spectrally selective waveguides," *Nature Communications*, vol. 9, no. 1, p. 3009, Aug 2018.
- [49] W. Shi, H. Yun, C. Lin, M. Greenberg, X. Wang, Y. Wang, S. T. Fard, J. Flueckiger, N. A. Jaeger, and L. Chrostowski, "Ultra-compact, flattop demultiplexer using anti-reflection contra-directional couplers for cwdm networks on silicon," *Optics express*, vol. 21, no. 6, pp. 6733– 6738, 2013.
- [50] J. Chen and Y. Shi, "Flat-top cwdm (de) multiplexers based on contradirectional couplers with subwavelength gratings," *IEEE Photonics Technology Letters*, vol. 31, no. 24, pp. 2003–2006, 2019.
- [51] W. Shi, X. Wang, C. Lin, H. Yun, Y. Liu, T. Baehr-Jones, M. Hochberg, N. A. Jaeger, and L. Chrostowski, "Silicon photonic grating-assisted, contra-directional couplers," *Optics express*, vol. 21, no. 3, pp. 3633– 3650, 2013.
- [52] D. Charron, J. St-Yves, O. Jafari, S. LaRochelle, and W. Shi, "Subwavelength-grating contradirectional couplers for large stopband filters," *Optics letters*, vol. 43, no. 4, pp. 895–898, 2018.
- [53] S. Lin, M. Hammood, H. Yun, E. Luan, N. A. Jaeger, and L. Chrostowski, "Computational lithography for silicon photonics design," *IEEE Journal of Selected Topics in Quantum Electronics*, vol. 26, no. 2, pp. 1–8, 2019.
- [54] S. A. Miller, Y. Okawachi, S. Ramelow, K. Luke, A. Dutt, A. Farsi, A. L. Gaeta, and M. Lipson, "Tunable frequency combs based on dual microring resonators," *Opt. Express*, vol. 23, no. 16, pp. 21527–21540, Aug 2015.
- [55] B. Y. Kim, Y. Okawachi, J. K. Jang, M. Yu, X. Ji, Y. Zhao, C. Joshi, M. Lipson, and A. L. Gaeta, "Turn-key, high-efficiency kerr comb source," *Opt. Lett.*, vol. 44, no. 18, pp. 4475–4478, Sep 2019.
- [56] L. Chang, S. Liu, and J. E. Bowers, "Integrated optical frequency comb technologies," *Nature Photonics*, vol. 16, no. 2, pp. 95–108, 2022.
- [57] S. Liu, X. Wu, D. Jung, J. C. Norman, M. J. Kennedy, H. K. Tsang, A. C. Gossard, and J. E. Bowers, "High-channel-count 20 ghz passively mode-locked quantum dot laser directly grown on si with 4.1 tbit/s transmission capacity," *Optica*, vol. 6, no. 2, pp. 128–134, Feb 2019.
- [58] G. Kurczveil, A. Descos, D. Liang, M. Fiorentino, and R. Beausoleil, "Hybrid silicon quantum dot comb laser with record wide comb width," in *Frontiers in Optics*. Optical Society of America, 2020, pp. FTu6E– 6.
- [59] G. Kurczveil, M. A. Seyedi, D. Liang, M. Fiorentino, and R. G. Beausoleil, "Error-free operation in a hybrid-silicon quantum dot comb laser," *IEEE Photonics Technology Letters*, vol. 30, no. 1, pp. 71–74, 2017.
- [60] M. Zhang, B. Buscaino, C. Wang, A. Shams-Ansari, C. Reimer, R. Zhu, J. M. Kahn, and M. Lončar, "Broadband electro-optic frequency comb generation in a lithium niobate microringzhna resonator," *Nature*, vol. 568, no. 7752, pp. 373–377, 2019.
- [61] L. Chang, W. Xie, H. Shu, Q.-F. Yang, B. Shen, A. Boes, J. D. Peters, W. Jin, C. Xiang, S. Liu *et al.*, "Ultra-efficient frequency comb gener-

ation in algaas-on-insulator microresonators," *Nature communications*, vol. 11, no. 1, pp. 1–8, 2020.

- [62] Y. Hu, M. Yu, B. Buscaino, N. Sinclair, D. Zhu, R. Cheng, A. Shams-Ansari, L. Shao, M. Zhang, J. M. Kahn *et al.*, "High-efficiency and broadband electro-optic frequency combs enabled by coupled microresonators," *arXiv preprint arXiv:2111.14743*, 2021.
- [63] Y. Okawachi, K. Saha, J. S. Levy, Y. H. Wen, M. Lipson, and A. L. Gaeta, "Octave-spanning frequency comb generation in a silicon nitride chip," *Optics letters*, vol. 36, no. 17, pp. 3398–3400, 2011.
- [64] J. K. Jang, Y. Okawachi, Y. Zhao, X. Ji, C. Joshi, M. Lipson, and A. L. Gaeta, "Conversion efficiency of soliton kerr combs," *Optics Letters*, vol. 46, no. 15, pp. 3657–3660, 2021.
- [65] B. Y. Kim, J. K. Jang, Y. Okawachi, X. Ji, M. Lipson, and A. L. Gaeta, "Synchronization of nonsolitonic kerr combs," *Science Advances*, vol. 7, no. 43, p. eabi4362, 2021.
- [66] B. Y. Kim, Y. Okawachi, J. K. Jang, X. Ji, M. Lipson, and A. L. Gaeta, "Coherent combining for high-power kerr combs," in *CLEO: Science* and Innovations. Optica Publishing Group, 2022, pp. STh2F–6.
- [67] X. Ji, F. A. S. Barbosa, S. P. Roberts, A. Dutt, J. Cardenas, Y. Okawachi, A. Bryant, A. L. Gaeta, and M. Lipson, "Ultra-low-loss on-chip resonators with sub-milliwatt parametric oscillation threshold," *Optica*, vol. 4, no. 6, pp. 619–624, Jun 2017.
- [68] X. Ji, S. Roberts, M. Corato-Zanarella, and M. Lipson, "Methods to achieve ultra-high quality factor silicon nitride resonators," *APL Photonics*, vol. 6, no. 7, p. 071101, 2021.
- [69] X. Jiang, Y. Yang, H. Zhang, J. Peng, Y. Zhang, C. Qiu, and Y. Su, "Design and experimental demonstration of a compact silicon photonic interleaver based on an interfering loop with wide spectral range," *Journal of Lightwave Technology*, vol. 35, no. 17, pp. 3765–3771, 2017.
- [70] Z. Lu, H. Yun, Y. Wang, Z. Chen, F. Zhang, N. A. F. Jaeger, and L. Chrostowski, "Broadband silicon photonic directional coupler using asymmetric-waveguide based phase control," *Opt. Express*, vol. 23, no. 3, pp. 3795–3808, Feb 2015.
- [71] J. E. Cunningham, I. Shubin, X. Zheng, T. Pinguet, A. Mekis, Y. Luo, H. Thacker, G. Li, J. Yao, K. Raj, and A. V. Krishnamoorthy, "Highlyefficient thermally-tuned resonant optical filters," *Opt. Express*, vol. 18, no. 18, pp. 19055–19063, Aug 2010.
- [72] P. Sun and R. M. Reano, "Submilliwatt thermo-optic switches using free-standing silicon-on-insulator strip waveguides," *Opt. Express*, vol. 18, no. 8, pp. 8406–8411, Apr 2010.
- [73] M. van Niekerk, V. Deenadalayan, A. Rizzo, G. Leake, D. Coleman, C. C. Tison, M. L. Fanto, K. Bergman, and S. Preble, "Wafer-scalecompatible substrate undercut for ultra-efficient soi thermal phase shifters," in *CLEO: Science and Innovations*. Optical Society of America, 2022, pp. 1–2.
- [74] A. Rizzo, U. Dave, A. Freitas, S. P. Roberts, A. Novick, M. Lipson, and K. Bergman, "Fabrication-robust silicon photonics platform in standard 220 nm silicon processes," in 2021 IEEE 17th International Conference on Group IV Photonics (GFP), 2021, pp. 1–2.
- [75] L. Song, H. Li, and D. Dai, "Mach-zehnder silicon-photonic switch with low random phase errors," *Opt. Lett.*, vol. 46, no. 1, pp. 78–81, Jan 2021.
- [76] T. Fujisawa, S. Makino, T. Sato, and K. Saitoh, "Low-loss, compact, and fabrication-tolerant si-wire 90° waveguide bend using clothoid and normal curves for large scale photonic integrated circuits," *Optics Express*, vol. 25, no. 8, pp. 9150–9159, 2017.
- [77] F. Vogelbacher, S. Nevlacsil, M. Sagmeister, J. Kraft, K. Unterrainer, and R. Hainberger, "Analysis of silicon nitride partial euler waveguide bends," *Optics Express*, vol. 27, no. 22, pp. 31 394–31 406, 2019.
- [78] M. Bahadori, M. Nikdast, Q. Cheng, and K. Bergman, "Universal design of waveguide bends in silicon-on-insulator photonics platform," *Journal of Lightwave Technology*, vol. 37, no. 13, pp. 3044–3054, 2019.
- [79] M. Cherchi, S. Ylinen, M. Harjanne, M. Kapulainen, and T. Aalto, "Dramatic size reduction of waveguide bends on a micron-scale silicon photonic platform," *Optics express*, vol. 21, no. 15, pp. 17814–17823, 2013.
- [80] M. T. Wade, "Devices and systems-on-chip for photonic communication links in a microprocessor," Ph.D. dissertation, University of Colorado at Boulder, 2015.
- [81] E. Timurdogan, C. M. Sorace-Agaskar, E. S. Hosseini, G. Leake, D. D. Coolbaugh, and M. R. Watts, "Vertical junction silicon microdisk modulator with integrated thermal tuner," in *CLEO: 2013*. Optical Society of America, 2013, p. CTu2F.2.
- [82] I.-L. Gheorma and R. Osgood, "Fundamental limitations of optical resonator based high-speed eo modulators," *IEEE Photonics Technology Letters*, vol. 14, no. 6, pp. 795–797, 2002.

- [83] M. de Cea, A. H. Atabaki, and R. J. Ram, "Power handling of silicon microring modulators," *Opt. Express*, vol. 27, no. 17, pp. 24274– 24285, Aug 2019.
- [84] "Ansys-Lumerical. high-performance photonic simulation software," http://lumerical.com.
- [85] R. Soref et al., "Electrooptical effects in silicon," IEEE Journal of Quantum Electronics, vol. 23, no. 1, pp. 123–129, 1987.
- [86] "Lumerical white paper, interconnect: Enabling time and frequency domain simulation of photonic integrated circuits with microring modulators," Jan 2020. [Online]. Available: https://www.lumerical.com/learn/whitepapers/interconnect-enablingtime-and-frequency-domain-simulation-of-photonic-integrated-circuitswith-microring-modulators/
- [87] J. Sun, R. Kumar, M. Sakib, J. B. Driscoll, H. Jayatilleka, and H. Rong, "A 128 gb/s pam4 silicon microring modulator with integrated thermooptic resonance tuning," *J. Lightwave Technol.*, vol. 37, no. 1, pp. 110– 115, Jan 2019.
- [88] V. Murthy, A. Rizzo, G. Leake, N. Mehta, A. Novick, S. Daudlin, M. Haatnik, M. van Niekerk, M. Fanto, D. Coleman *et al.*, "Mitigation of parasitic junction formation in compact resonant modulators with doped silicon heaters," in *Laser Resonators, Microresonators, and Beam Control XXIV*, vol. 11987. SPIE, 2022, pp. 114–125.
- [89] D. Coenen, H. Oprins, Y. Ban, F. Ferraro, M. Pantouvaki, J. Van Campenhout, and I. De Wolf, "Thermal modelling of silicon photonic ring modulator with substrate undercut," *Journal of Lightwave Technology*, 2022.
- [90] M. Georgas, J. Leu, B. Moss, C. Sun, and V. Stojanović, "Addressing link-level design tradeoffs for integrated photonic interconnects," in 2011 IEEE Custom Integrated Circuits Conference (CICC). IEEE, 2011, pp. 1–8.
- [91] M. Bahadori, S. Rumley, R. Polster, A. Gazman, M. Traverso, M. Webster, K. Patel, and K. Bergman, "Energy-performance optimized design of silicon photonic interconnection networks for high-performance computing," in *Design, Automation & Test in Europe Conference & Exhibition (DATE), 2017.* IEEE, 2017, pp. 326–331.
- [92] A. Rizzo, Y. London, G. Kurczveil, T. Van Vaerenbergh, M. Fiorentino, A. Seyedi, D. Livshits, R. G. Beausoleil, and K. Bergman, "Energy efficiency analysis of frequency comb sources for silicon photonic interconnects," in 2019 IEEE Optical Interconnects Conference (OI), 2019, pp. 1–2.
- [93] J. K. Jang, A. Klenner, X. Ji, Y. Okawachi, M. Lipson, and A. L. Gaeta, "Synchronization of coupled optical microresonators," *Nature Photonics*, vol. 12, no. 11, pp. 688–693, Nov 2018.
- [94] G. B. Morrison, B. Buckley, J. Sherman, K. Ottosson, H. Grant, P. O. Leisher, J. Campbell, F. Foong, D. Renner, L. Johansson, and M. Mashanovitch, "High power single mode photonic integration," in 2019 IEEE High Power Diode Lasers and Systems Conference (HPD), 2019, pp. 47–48.
- [95] H. Jayatilleka, H. Frish, R. Kumar, J. Heck, C. Ma, M. N. Sakib, D. Huang, and H. Rong, "Post-fabrication trimming of silicon photonic ring resonators at wafer-scale," *Journal of Lightwave Technology*, vol. 39, no. 15, pp. 5083–5088, 2021.
- [96] B. Guha, J. Cardenas, and M. Lipson, "Athermal silicon microring resonators with titanium oxide cladding," *Opt. Express*, vol. 21, no. 22, pp. 26557–26563, Nov 2013.
- [97] V. Gopal, A. Novick, A. Rizzo, S. Daudlin, X. Ji, B. Y. Kim, Y. Okawachi, M. Lipson, A. Gaeta, and K. Bergman, "Concurrent error-free modulation of adjacent kerr comb lines on a silicon chip," in *CLEO: Science and Innovations*. Optical Society of America, 2022, pp. 1–2.
- [98] S. Daudlin, A. Novick, M. Hattink, V. Gopal, A. Rizzo, B. Y. Kim, X. Ji, Y. Okawachi, A. Gaeta, M. Lipson, and K. Bergman, "Integrated kerr comb link with silicon photonic receiver," in *CLEO: Science and Innovations*. Optical Society of America, 2022, pp. 1–2.
- [99] L. Chrostowski and M. Hochberg, Silicon photonics design: from devices to systems. Cambridge University Press, 2015.
- [100] C. Sun, M. T. Wade, Y. Lee, J. S. Orcutt, L. Alloatti, M. S. Georgas, A. S. Waterman, J. M. Shainline, R. R. Avizienis, S. Lin, B. R. Moss, R. Kumar, F. Pavanello, A. H. Atabaki, H. M. Cook, A. J. Ou, J. C. Leu, Y.-H. Chen, K. Asanović, R. J. Ram, M. A. Popović, and V. M. Stojanović, "Single-chip microprocessor that communicates directly using light," *Nature*, vol. 528, no. 7583, pp. 534–538, Dec 2015.
- [101] M. Rakowski, Y. Ban, P. De Heyn, N. Pantano, B. Snyder, S. Balakrishnan, S. Van Huylenbroeck, L. Bogaerts, C. Demeurisse, F. Inoue *et al.*, "Hybrid 14nm finfet-silicon photonics technology for low-power tb/s/mm 2 optical i/o," in 2018 IEEE Symposium on VLSI Technology. IEEE, 2018, pp. 221–222.

- [102] "Corning specialty fiber product information sheets." [Online]. Available: https://www.corning.com/microsites/coc/oem/documents/specialtyfiber/Corning-Specialty-Fiber-Product-Information-Sheets-111913.pdf
- [103] O. A. J. Gordillo, U. D. Dave, and M. Lipson, "Bridging between si and few-mode fiber higher order modes," in *CLEO: Science and Innovations*. Optical Society of America, 2020, pp. SM2O–6.
- [104] —, "One-to-one coupling higher order modes in a fiber to higher order modes in silicon waveguide," in *CLEO: Science and Innovations*. Optical Society of America, 2021, pp. SW3C–4.
- [105] L.-W. Luo, N. Ophir, C. P. Chen, L. H. Gabrielli, C. B. Poitras, K. Bergman, and M. Lipson, "Wdm-compatible mode-division multiplexing on a silicon chip," *Nature communications*, vol. 5, no. 1, pp. 1–7, 2014.
- [106] X. Mu, S. Wu, L. Cheng, and H. Fu, "Edge couplers in silicon photonic integrated circuits: A review," *Applied Sciences*, vol. 10, no. 4, 2020.
- [107] Y.-H. Hung, Q. Cheng, M. Glick, M. Badahori, L. Y. Dai, and K. Bergman, "Silicon photonic switch-based optical equalization for mitigating pulsewidth distortion," *Opt. Express*, vol. 27, no. 14, pp. 19 426–19 435, Jul 2019.
- [108] S. Saeedi, S. Menezo, G. Pares, and A. Emami, "A 25 gb/s 3d-integrated cmos/silicon-photonic receiver for low-power highsensitivity optical communication," *Journal of Lightwave Technology*, vol. 34, no. 12, pp. 2924–2933, 2016.

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